

530 Rec'd PCT/PTO 25 JUN 2002

Receipt
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PATENT
Attorney Docket No. 401479

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

IZUO et al.

Application No. 10/009,521

Filed: December 11, 2001

For: ELECTROCHEMICAL ETCHING
METHOD AND APPARATUS AND
PRODUCT MANUFACTURED
THEREBY

Art Unit: 2855

Examiner: Unassigned

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REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT

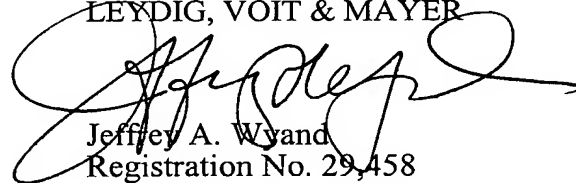
Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

An error has been noted on the Official Filing Receipt in the referenced application, namely, the fourth applicant's name is misspelled. Please issue a Corrected Official Filing Receipt correcting this error as marked in red on the attached copy of the Official Filing Receipt.

Respectfully submitted,

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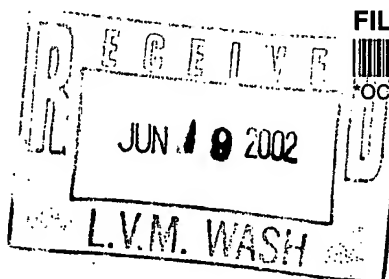
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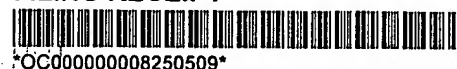
APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
10/009,521	12/11/2001	2855	974	401479	12	18	3

CONFIRMATION NO. 4369

23548
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FILING RECEIPT



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Date Mailed: 06/13/2002

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Applicant(s)

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Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP00/03307 05/24/2000

Foreign Applications

Projected Publication Date: Not Applicable, filed prior to November 29, 2000

Non-Publication Request: No

Early Publication Request: No

Title

Method and apparatus for radiation assisted electrochemical etching and etched product

Preliminary Class

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